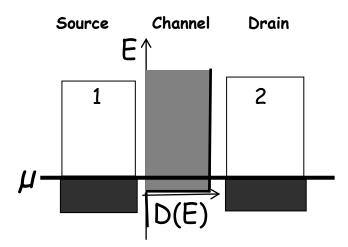
ECE 495N, Fall'08 ME118, MWF 1130A-1220P

Fundamentals of Nanoelectronics

HW#2: Due Wednesday Sept.10 in class.

Please turn in a copy of your MATLAB codes for Problems 1, 2.

Consider the same problem as in HW 1, namely a channel with a density of states given by, $D(E) = D_0 \ \mathcal{G}(E)$, where \mathcal{G} represents the unit step function. The equilibrium electrochemical potential $\mu = 0.1$ eV and $k_B T_1 = k_B T_2 = 0.025 \ eV$. Assume the escape rates γ_1 and γ_2 to both be equal to 10 meV, and the density of states (for E>0) D_0 to be $0.1 \ / \ eV$.



Problems 1 and 2 below require a computer evaluation of the current expression discussed

in class:

$$I = \frac{q}{\hbar} \int_{-\infty}^{+\infty} dE D(E - U) \frac{\gamma_1 \gamma_2}{\gamma_1 + \gamma_2} \left[f_1(E) - f_2(E) \right]$$
(1)

but Problem 2 also requires an additional self-consistent evaluation of U from the equations

$$N = \int_{-\infty}^{+\infty} dE D(E - U) \frac{\gamma_1 f_1(E) + \gamma_2 f_2(E)}{\gamma_1 + \gamma_2}$$
 (2)

and
$$U = U_L + U_0(N - N_{eq})$$
 (3)

Problem 1: Calculate the current (I) versus drain voltage (V_D) for $-0.4 \text{V} < V_D < +0.4 \text{V}$ assuming $U_0 = 0$, and

(a)
$$U_L = 0.5 * (U_{source} + U_{drain}),$$

- (b) $U_L = U_{source}$,
- (c) $U_L = U_{drain}$.

Note that $U_{drain} = U_{source} - qV_D$, $\mu_1 = \mu + U_{source}$, $\mu_2 = \mu + U_{drain}$

Problem 2: Calculate the current (I) versus drain voltage (V_D) for $-0.4 \text{V} < V_D < +0.4 \text{V}$ assuming $U_0 = 5$ eV and $U_L = U_{source}$.

Problem 3: Electrons in a semiconductor obey a modified Schrodinger equation which in one dimension has the form

$$i\hbar\frac{\partial\psi}{\partial t} = -\frac{\hbar^2}{2m}\frac{\partial^2\psi}{\partial x^2} + \alpha\frac{\partial^4\psi}{\partial x^4}$$

where α and m are constants. Assume a solution of the form (ψ_0 being a constant)

$$\psi(x,t) = \psi_0 e^{ikx} e^{-iEt/\hbar}$$

to find the dispersion relation E (k).